## Supporting Information

## A High Responsivity, High Detectivity and High Response Speed MSM

## UVB Photodetector based on SnO<sub>2</sub> Microwires

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# S1 Comparisons between the fabricated $SnO_2$ MWs in this work and other previous reports

Tab. S1 shows the comparison of the device performance parameters for this work and some previous reports. Similar with the junction type devices, the SnO<sub>2</sub> MW in this work also shows relatively low dark current and response time, which is attributed to the relatively high crystal quality and small amount of oxygen vacancies existed inside the material. While different with the reported junction type devices, SnO<sub>2</sub> MW in this work shows higher responsivity and specific detectivity, which can be attributed to the excellent performance of carrier generation and transportation.

Material	Bias	Dark current	Responsivity	Detectivity	Response time	Ref.
	v	A	A·W <sup>−1</sup>	Jones	S	
SnO <sub>2</sub> /CsPbBr <sub>3</sub>	3	1.0×10 <sup>-10</sup>	2.0	1.2×10 <sup>13</sup>	1.94×10 <sup>-3</sup>	1
SnO <sub>2</sub>	3	1.0×10 <sup>-9</sup>			1.0	2
$\beta$ -Ga <sub>2</sub> O <sub>3</sub> /SnO <sub>2</sub>	2	2.0×10 <sup>-9</sup>			28.0	3
SnO <sub>2</sub> /p-GaN	-3	1.6×10 <sup>-8</sup>	1.45	1.31×10 <sup>13</sup>	0.51	4
PEDOT:PSS/SnO <sub>2</sub>	-10	1.1×10 <sup>-4</sup>	1.8×10 <sup>-3</sup>			5
SnO <sub>2</sub> /p-InGaN	0		0.1	3.5×10 <sup>12</sup>	0.5	6
				(-0.1 V)		
SnO <sub>2</sub>	10	3.69×10 <sup>-9</sup>	1.353×10 <sup>3</sup>	5.4×10 <sup>14</sup>	< 8.0×10 <sup>-2</sup>	This
(322 nm,						work
0.25 μW/cm²)						

Tab. S1 Con	nparisons between	the fabricated SnO-	MWs in this work	and other	previous re	ports.
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#### S2 The absorption spectrum of single SnO<sub>2</sub> MW



Fig. S1 Absorption spectrum of single SnO2 MW

### S3 The element content and distribution of SnO<sub>2</sub> MWs



Fig. S2 (a) The SEM image of  $SnO_2$  MWs; (b) the measured distribution spectrum of elements; (c - d) the measured element mappings of O and Sn elements in  $SnO_2$  MWs.

### References

1 Y. Zhang, W. Xu, X. Xu, J. Cai, W. Yang and X. Fang, J. Phys. Chem. Lett., 2019, 10, 836-841.

2 J. Cai, X. Xu, L. Su, W. Yang, H. Chen, Y. Zhang and X. Fang, Adv. Opt. Mater., 2018, 6, 1800213.

3 K. Liu, M. Sakurai and M. Aono, J. Mater. Chem., 2012, 22, 12882-12887.

- 4 T. Xu, M. Jiang, P. Wan, K. Tang, D. Shi and C. Kan, *Photonics Res.*, 2021, 9, 2475-2485.
- 5 S. Li, S. Wang, K. Liu, N. Zhang, Z. Zhong, H. Long and G. Fang, *Appl. Phys. A*, 2015, 119, 1561-1566.
- 6 Y. Zhang, T. Xu, K. Chang, S. Cao, P. Wan, D. Shi, C. Kan and M. Jiang, *Results Phys.*, 2022, 42, 105995.